

# Robust Electronic Structure of Manganite-Buffered Oxide Interfaces with Extreme Mobility Enhancement

Hang Li, Yulin Gan, Marius-Adrian Husanu, Rasmus Tindal Dahm, Dennis Valbjørn Christensen, Milan Radovic, Jirong Sun, Ming Shi, Baogen Shen, Nini Pryds,\* and Yunzhong Chen\*



unambiguous evidence that the insertion of the LMO buffer strongly suppresses both the formation of oxygen vacancies as well as the electron-phonon interaction on the STO side. The latter effect makes the buffered sample different from any other STO-based interfaces and may explain the maximum mobility enhancement achieved at buffered oxide interfaces.

**KEYWORDS:** oxide interfaces, high mobility 2DEG, electronic structure, electron-phonon interaction, resonant angle-resolved photoemission spectroscopy

### **INTRODUCTION**

The two-dimensional electron gas (2DEG) formed at the interface between two oxide band insulators, LaAlO<sub>3</sub>/SrTiO<sub>3</sub> (LAO/STO), in particular,<sup>1</sup> exhibits exotic physical properties such as superconductivity,<sup>2-6</sup> magnetism,<sup>7-10</sup> Rashba-type spin–orbit coupling,<sup>11,12</sup> and the quantum Hall effect.<sup>13,14</sup> However, the origin of the conduction as well as the role of asgrown defects such as oxygen vacancies (OVs) on the conduction have often been topics of hot debate. In addition to the polar discontinuity-induced electronic and ionic reconstructions,  $^{1,15-17}_{1,15-17}$  OVs resulting from vacuum anneal-ing,  $^{16-19}_{10}$  light irradiation,  $^{20-24}$  or interfacial redox reaction<sup>25-27</sup> could also generate electrons, giving a large or even dominating contribution to the conduction. Regardless of the exact origin of the conduction, for most 2DEG systems related to STO, bare STO surface, or STO-based interfaces, the itinerant charges occupy the conduction band of STO with lower energy, which consists of exclusively Ti  $t_{2g}$  ( $d_{xy}$  and  $d_{xz}/d_{yz}$ ) orbitals (Figure 1a).<sup>28–31</sup> The electrons of the  $d_{xy}$  orbitals, contributing to the most carrier concentration, are strongly confined near the surface/interface of STO, forming quasi-2D subbands (Figure 1a), known as the light band with low

effective mass. Meanwhile, the  $d_{xz}/d_{yz}$  orbitals construct heavy bands with large effective mass while their wave functions extend deep into the bulk STO resulting in quasi-3D character (Figure 1 a).<sup>32</sup> As for the band character of each  $t_{2g}$  band,  $d_{xy}$ orbitals construct the circular electron pocket at the Fermi surface (FS), and the other two elliptical pockets are constructed by  $d_{xz}$  and  $d_{yz}$  orbitals, as revealed in Figure 1d. Compared with heavy  $d_{xz}/d_{yz}$  bands, the light  $d_{xy}$  band hosts larger bandwidth and smaller Fermi momenta ( $k_{\rm F}$ ) (Figure 1d).

Despite the intensive research, to date, one of the key challenges of STO 2DEGs is increasing the carrier mobility and revealing the underlying mechanism. The  $d_{xy}$  electrons, residing in closer proximity to the interface, have a smaller effective mass compared to the  $d_{xz}/d_{yz}$  ones, but their mobility

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Figure 1. (a) Quantum-well states of 2DEG formed by wedgelike potential near the surface/interface of STO. Bold black curve shows the conduction band profile  $(E_C)$ . The insert panel shows the unit cell and  $d_{xy}/d_{xz}/d_{yz}$  orbitals of STO. The positive and negative lobes of the orbitals are shown in orange and blue, respectively. (b) 3D Brillouin zone (BZ) of STO-based systems. (c,d) Typical FS pattern and electronic structure of a STO 2DEG system, respectively.

is often lower probably due to a large defect concentration at the interface.<sup>33</sup> For most STO-based 2DEGs, the typical carrier mobility is around 1000 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> at low temperatures. This is expected to be further decreased under light irradiation in

high vacuum as significant oxygen-deficiency develops during light exposure.  $^{22,32-34}$  Notably, recent studies show that the carrier mobility can be significantly enhanced by deliberate surface or interface engineering. $^{35-41}$  One significant example is the insertion of a single unit cell of epitaxial LaMnO3 (LMO) at the interface between amorphous-LaAlO<sub>3</sub> and STO substrate (a-LAO/LMO/STO),<sup>39</sup> where an electron sink of Mn<sup>3+</sup> in the perovskite structure was used to decrease the carrier density of 2DEG on the STO side through interfacial charge transfer.<sup>39</sup> The introduction of the manganite buffer layer decreases the carrier density by approximately 1 order of magnitude, wherea the carrier mobility is increased 10-100 times compared to the unbuffered a-LAO/STO.<sup>39</sup> It also leads to the observation of a clear quantum Hall effect at complex oxide interfaces.<sup>13</sup> However, the electronic structure of these buffered oxide interfaces with enhanced carrier mobility remains to be determined. Identifying the electronic structure as well as the orbital configuration becomes even more interesting upon the recent finding that the high mobility 2DEG at  $\gamma$ -Al<sub>2</sub>O<sub>3</sub>/STO (GAO/STO) interface shows an anomaly in orbital ordering as well as a weak electron-phonon interaction (EPI) strength of the carriers.<sup>42,43</sup>

In this paper, we identify the electronic band structure of the buried oxide interfaces by soft X-ray angle-resolved photoemission spectroscopy (ARPES) for both bare and LMObuffered *a*-LAO/STO. Besides a slight decrease in the  $k_{\rm F}$  and carrier density as well as a strong suppression in the concentration of OVs,<sup>39</sup> the buffered interface exhibits two significant properties: (1) an unexpected irradiation-robust band structure, which reflects the detection of FS of intrinsic interface states, and (2) a significantly reduced EPI strength, which is absent in the nonbuffered<sup>42,43</sup> as well as the diluted crystalline LAO/STO interfaces. The combined effect of the



Figure 2. (a) Sketches of the modulation-doped *a*-LAO/LMO/STO with the experimental geometry for the ARPES measurement. The gray arrows represent the *s*- and *p*-polarization of X-rays. (b) Sketches of resonant photoemission process in STO-based 2DEG systems. (c,e) FS maps and band dispersions measured at C + polarization of *a*-LAO/STO and *a*-LAO/LMO/STO (t = 1uc) at  $E_F$  in  $k_z = 0$  plane, respectively. The black circles and red ellipses indicate the FS of  $d_{xy}$  and  $d_{xz}/d_{yz}$  orbitals, respectively. (d,f) Electronic structures along  $k_x$  measured with *s*-polarization of *a*-LAO/LMO/STO, respectively. Black and red curves mark the band structure of  $d_{xy}$  and  $d_{yz}$  orbitals, respectively. Black and red dashed curves mark the pronounced tail of polarons induced by EPI. All data are recorded at Ti *L*-edge resonant energy, which corresponds to the  $k_z = 7 \times 2 \pi/a$  plane in the BZ of STO (Figure S1).

reduction in the carrier density, the suppression of defect concentration of OVs, as well as the decrease in the EPI strength on the STO side could account for the extreme mobility of the buffered oxide heterostructures.

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#### **RESULTS AND DISCUSSION**

The interfacial 2DEG locates on the STO side in close proximity to the interface underneath the capping layer, which is generally thicker than 1.6 nm. To investigate the band structures of these heterostructures, we used soft X-ray ARPES, where the photoelectrons have an escape depth sufficiently large to probe buried interfaces,<sup>42–47</sup> as illustrated in Figure 2a for *a*-LAO/LMO/STO.

First, we identified the FS maps and band dispersions for *a*-LAO/STO heterointerfaces with and without LMO buffer. The resonant photon energies are determined by *hv*-dependent ARPES intensity map at  $E_{\rm F}$  (see Figure S1). As revealed in Figure 2c,e, the experimental FS map consists of one circular electron pocket located at the center of Brillouin zone (BZ) and two other intersecting elliptical electron pockets aligned along the  $k_x$  and  $k_y$  directions (the two  $\Gamma$ -X directions in the BZ). This is a typical FS pattern of the STO-based 2DEG systems (Figure 1c).<sup>31,32,42,43</sup>

The band dispersions of a-LAO/STO and a-LAO/LMO/ STO (t = 1 uc) along the  $k_x$  direction were measured with linear s-polarized light (Figure 2a), which probe mostly the antisymmetric  $d_{xy}$  and  $d_{yz}$  orbitals, whereas the symmetric  $d_{xz}$ ones can be probed by the p-polarized light.44,45 As shown in Figure 2d,f, we can clearly identify the light  $d_{xy}$  band and heavy  $d_{yz}$  bands near the second  $\Gamma$ -point for a-LAO/STO and a-LAO/LMO/STO (t = 1 uc), respectively. Similar to most other STO-based systems, the Ti  $t_{2g}$  bands are reconstructed at the interface to form deep  $d_{xy}$  subbands and shallow  $d_{xz/yz}$ bands (Figure 1d). This is due to the confined quantum well states with the bended band profiles near the surface region, which can be estimated by the binding energies of Ti 2p orbitals. However, our result (Figure.S2) shows a similar value compared with pristine STO,48° probably due to the limited energy resolutions. The pronounced intensity tail of these bands extending to higher binding energy is a sign of the strong polaronic coupling of charge carriers in these systems,<sup>42,43</sup> which results in the discontinuity of band structures.

It has been found that STO-based 2DEG is often sensitive to the X-ray irradiation<sup>22,32,34,46</sup> during ARPES measurements, where the photogenerated extra carriers could be used to tune the interface states, but it also makes the detection of the intrinsic electronic structure of interfacial 2DEGs challenging. Such an X-ray irradiation effect is demonstrated by the monotonous growth in the intensity of the 2DEG with respect to the X-ray exposure time as observed in a-LAO/STO (Figure 3a,c). On the contrary, we find that the intensity of the 2DEG in buffered sample shows a negligible increase during X-ray exposure (Figure 3b,c). The X-ray irradiation generated 2DEG is generally due to the formation of oxygen vacancies. We thus investigated the evolution of the in-gap states of OVs, which are located  $E_{\rm B} \sim 1.2$  eV below the Fermi energy level  $(E_{\rm F})$ (Figure S3). As shown in Figure 3d, the intensity of IGS for both buffered and unbuffered a-LAO/STO increases with respect to irradiation time. Notably, the intensity of the in-gap states increases at a rate much faster than that of the 2DEG for both samples, indicating that the photocreated OVs not only contribute to the extra mobile carriers but also localized



Figure 3. k-resolved intensity maps as a function of irradiation time at  $E_{\rm F}$  of *a*-LAO/STO (a) and *a*-LAO/LMO/STO (t = 1 uc) (b), respectively. (c,d) Integrated intensities of 2DEG and OVs ingap states (IGS) of *a*-LAO/STO and *a*-LAO/LMO/STO, respectively, as a function of irradiation time. (e) Time-dependent intensity change [ $(I_t - I_0)/I_0$ ] of 2DEG and OVs IGS for both *a*-LAO/STO and *a*-LAO/STO.

carriers. As far as *a*-LAO/LMO/STO is concerned, because of the nearly constant intensity of 2DEG with respect to X-ray irradiation, the difference in the intensity between the in-gap state of OVs and the 2DEG increases with respect to irradiation time although it has a slower rate compared to the unbuffered sample. This indicates two effects: first, the introduction of the LMO spacer suppresses the formation of OVs in the buffered sample; second, even though there are irradiation—induced in gap states in buffered samples, the photogenerated extra carriers are most likely transferred to the manganite buffer layer instead of 2DEG conduction layer. This is consistent with the electron sink role of LMO buffer layer. As a consequence, the LMO buffer layer renders the intrinsic electronic structure robust toward X-ray radiation.

Another feature of the buffered oxide interface is the strongly suppressed EPI. Besides electron-electron interactions, EPI is an important factor in STO affecting the charge transport and carrier mobility whereby the electrons drag behind a local perturbation of the crystal lattice as described by the concept of polarons.<sup>44</sup> Their signature in the experimental spectral function  $A(\mathbf{k},\omega)$  is observed from the energy distribution curves (EDCs) as a peak-dip-hump structure, where the hump below the quasiparticle (QP) peak is formed by the EPI with the peak-to-hump distance reflecting the energy of the involved phonon modes. Figure 4c shows the EDCs of a-LAO/STO and a-LAO/LMO/STO, where the corresponding integration range is marked by the white box in Figure 4a,b for zoom-in band structures measured along  $k_x$ with s-polarized light. Both EDCs show clear QP peaks near  $E_{\rm F}$ followed by an intensity tail at higher binding energy, consistent with previous observations in nonbuffered STObased systems.<sup>42,44,45</sup> The characteristic EPI-induced polaronic tail extends down to  $E_b = -1$  eV. Notably, unlike stoichiometric crystalline LAO/STO<sup>44</sup> or GAO/STO,<sup>42</sup> which exhibit clear satellite peaks for the LO<sub>3</sub> phonon mode, the hump lineshapes for these materials are structureless and extend over a wide energy range, suggesting that multiple phonon modes are involved in the EPI. The EPI strength is



Figure 4. (a,b) Zoom-in band structures of *a*-LAO/STO and modulation-doped *a*-LAO/LMO/STO (t = 1 uc) measured along  $k_x$  with *s*-polarized light, respectively. (c) Integrated EDCs of  $d_{xy}$  orbitals (marked a and b). Red and blue dots show the raw integrated EDCs of *a*-LAO/LMO/STO and *a*-LAO/STO, respectively. Filled dark red and blue curves show the fitted corresponding QP peaks. Dashed curves show the fitted hump peaks. Red and blue curves show the fitted EDCs combined by QP peaks and hump peaks.

related to the QP residual weight,  $Z_{0}^{44,45}$  which is calculated as  $Z_0 = I_{\rm QP}/(I_{\rm QP} + I_{\rm hump})$ , with  $I_{\rm QP}$  and  $I_{\rm hump}$  representing the integrated spectral weight of QP and residuals from EDCs, respectively. Larger  $Z_0$  values identify heavier QP spectral weight thus smaller EPI. Our quantitative analyses show that  $Z_0$  increases from 33% in *a*-LAO/STO to 46% in *a*-LAO/LMO/STO (Figure 4c). Since these two systems host a similar band structure and bandwidth (~80 meV in *a*-LAO/STO and ~90 meV in *a*-LAO/LMO/STO, see the Supporting Information Figure.S4), the increase in  $Z_0$  suggests a significant decrease of EPI strength upon the introduction of the single unit cell LMO buffer, which can fundamentally enhance the carrier mobility as discussed below.<sup>41</sup>

In STO 2DEGs, the carrier mobility is limited by several crucial ingredients including defect concentration, strong EPI, and to a lesser extent, electron-electron correlations. The EPI will result in the polaronic nature of the interfacial charge carriers that increases their effective mass,<sup>40</sup> whereas defects at the interface will increase the impurity scattering of carriers. Both effects will decrease the carrier mobility. For the unbuffered a-LAO/STO, its concentration of OVs is high as expressed by the high intensity of in-gap states (Figure 3). The buffered sample shows much reduced in-gap states thus low OVs, which could explain partially the mobility enhancement. Notably, the  $Z_0$  of the LMO-buffered sample increases to 46% in comparison to  $\sim$ 33% for *a*-LAO/STO. Previous studies on the temperature-dependent EPI effect of LAO/STO reveal that when  $Z_0$  is increased from ~30% to ~40% the carrier mobility of 2DEG could be enhanced around 10 times.<sup>44</sup> It is noteworthy that a similar large  $Z_0$  value of buffered sample is also obtained in GAO/STO,<sup>42</sup> the carrier mobility of which can be up to 140000 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>. Therefore, the nontrivial significant increase in  $Z_0$  and, thus, the strong decrease in EPI of buffered oxide interfaces, on top of the suppression of the OVs, may be the main ingredient dominating the extreme mobility enhancement in buffered oxide interfaces. Additionally, as the EPI is often associated with superconductivity in STO-based systems, the strong suppression of the EPI in *a*-LAO/LMO/STO could well explain its absence of super-conductivity.<sup>13</sup>

#### CONCLUSIONS

In summary, we have studied in detail the electronic structure by soft X-ray ARPES of buffered oxide interfaces with enhanced electron mobility. The ARPES results reveal a nontrivial feature of weakened EPI strength concomitant with decreased formation of oxygen vacancies. The combination of these effects could explain the mobility enhancement and provide crucial insights in boosting the carrier mobility of engineered oxide heterostructures as well as the design of quantum oxide devices.

#### **METHODS**

**Sample Fabrication.** All heterostructures, *a*-LAO (~1.6 nm)/ LMO/STO with different thicknesses of LMO buffer layer (t = 0, 1 and 2 uc) were grown on TiO<sub>2</sub>-terminated STO substrates by pulse laser deposition (PLD) in an O<sub>2</sub> atmosphere of 10<sup>-4</sup> mbar. A KrF pulse laser (248 nm in wavelength, 1 Hz repetition frequency, 4.0 J/ cm<sup>2</sup> laser fluence) was adopted. For buffered/unbuffered *a*-LAO/ STO, amorphous LAO deposited at room temperature under 10<sup>-4</sup> mbar with single crystalline LAO as target. For the buffer layer, sintered LMO ceramics were used as targets and the growth temperature of LMO was fixed at 600 °C. After the epitaxial growth of monolayer LMO buffer layer, the sample was cooled under the deposition pressure at a nominal rate of 15 °C/min to room temperature (below 30 °C, in 5–6 h) before the subsequent *a*-LAO film deposition *in situ*.

**Angle-Resolved Photoemission Spectroscopy (ARPES).** The soft-X-ray ARPES measurements were performed at the ADRESS beamline<sup>49,50</sup> of the Swiss Light Source at Paul Scherrer Institute, Switzerland. The ARPES maps were recorded with a PHOIBOS-150 analyzer at an energy resolution of 60 meV and angular resolution of 0.1°. The samples were transferred *ex situ* and measured in the ARPES setup without annealing. All measurements are acquired at 12 K in a base pressure of better than  $5 \times 10^{-11}$  Torr.

#### ASSOCIATED CONTENT

#### **Supporting Information**

The Supporting Information is available free of charge at https://pubs.acs.org/doi/10.1021/acsnano.2c00609.

Additional data, including summary of EPI strength (Z<sub>0</sub>), concentration of the oxygen vacancies ( $n_{OV}$ ), Fermi momenta ( $k_{\rm F}$ ) of  $d_{xy}$  and  $d_{yz}$  bands, carrier density ( $n_{\rm s}$ ), and carrier mobility ( $\mu$ ) of the studied samples; photon-energy-dependent result; XPS of Ti 2p orbitals of *a*-LAO/STO and *a*-LAO/LMO/STO; irradiation-dependent OV-states in *a*-LAO/LMO/STO and *a*-LAO/LMO/STO and *a*-LAO/LMO/STO and *a*-LAO/LMO/STO are LAO/LMO/STO with 2 uc LMO buffer layer (PDF)

#### **AUTHOR INFORMATION**

#### **Corresponding Authors**

- Yunzhong Chen Beijing National Laboratory for Condensed Matter Physics and Institute of Physics, Chinese Academy of Sciences, 100190 Beijing, China; orcid.org/0000-0001-8368-5823; Email: yzchen@iphy.ac.cn
- Nini Pryds Department of Energy Conversion and Storage, Technical University of Denmark, 2800 Kgs. Lyngby, Denmark; orcid.org/0000-0002-5718-7924; Email: nipr@dtu.dk

#### Authors

Hang Li – Department of Energy Conversion and Storage, Technical University of Denmark, 2800 Kgs. Lyngby, Denmark; Swiss Light Source, Paul Scherrer Institute, 5232 Villigen, PSI, Switzerland

Yulin Gan – Beijing National Laboratory for Condensed Matter Physics and Institute of Physics, Chinese Academy of Sciences, 100190 Beijing, China

Marius-Adrian Husanu – National Institute of Materials Physics, 077125 Magurele, Romania; © orcid.org/0000-0003-4510-6653

**Rasmus Tindal Dahm** – Department of Energy Conversion and Storage, Technical University of Denmark, 2800 Kgs. Lyngby, Denmark

Dennis Valbjørn Christensen – Department of Energy Conversion and Storage, Technical University of Denmark, 2800 Kgs. Lyngby, Denmark; orcid.org/0000-0003-0048-7595

Milan Radovic – Swiss Light Source, Paul Scherrer Institute, 5232 Villigen, PSI, Switzerland

Jirong Sun – Beijing National Laboratory for Condensed Matter Physics and Institute of Physics, Chinese Academy of Sciences, 100190 Beijing, China

Ming Shi – Swiss Light Source, Paul Scherrer Institute, 5232 Villigen, PSI, Switzerland

Baogen Shen – Beijing National Laboratory for Condensed Matter Physics and Institute of Physics, Chinese Academy of Sciences, 100190 Beijing, China

Complete contact information is available at: https://pubs.acs.org/10.1021/acsnano.2c00609

#### **Author Contributions**

The manuscript was written through contributions of all authors. All authors have given approval to the final version of the manuscript. Y.Z.C. designed the concept and experiments with N.P.; H.L., Y.L.G., M.A.H., and R.T.D. performed the ARPES experiment; Y.L.G. and Y.Z.C. fabricated the samples and performed their transport characterization; H.L. and M.A.H. processed the ARPES data. All authors discussed the results and interpretations and wrote the manuscript.

#### Notes

The authors declare no competing financial interest.

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